## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: MAGRI' ET AL.

Serial No. **NOT YET ASSIGNED** 

Filing Date: HEREWITH

For: VERTICAL-CONDUCTION AND )
PLANAR-STRUCTURE MOS DEVICE)
WITH A DOUBLE THICKNESS OF )
GATE OXIDE AND METHOD )
REALIZING POWER VERTICAL )
MOS TRANSISTORS WITH )
IMPROVED STATIC AND DYNAMIC)
PERFORMANCES AND HIGH )

SCALING DOWN DENSITY

I HEREBY CERTIFY THIS PAPER OR FEE IS BEING DEPOSITED WITH THE U.S. POSTAL SERVICE "EXPRESS MAIL POST OFFICE TO ADDRESSEE" SERVICE UNDER 37 CFR 1.10 ON THE DATE INDICATED BELOW AND IS ADDRESSED TO: MAIL STOP PATENT APPLICATIONS, P.O. BOX 1450, ALEXANDRIA, VA 22313-1450.

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DATE OF DEPOSIT: \_December 30, 2003

NAME: Justin Goree

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## PRELIMINARY AMENDMENT

MS Patent Application Commissioner For Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Prior to the calculation of fees and examination of the present application, please enter the amendments and remarks set out below.